



IPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi TAKEI et al.

Group Art Unit: 2836

10/584,133

Examiner: S. W. Jackson

Filed: October 23, 2006

Docket No.: 128515

For: COMPOSITION FOR FORMING NITRIDE COATING FILM FOR HARD MASK

RESPONSE TO *EX PARTE* QUAYLE ACTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the *Ex Parte Quayle* Action mailed December 14, 2009, please consider the following:

Amendments to the Specification;

Amendments to the Claims as reflected in the listing of claims; and

Remarks.